ILE 'HOME' ENTERED AT 15:27:13 ON 01 OCT 2003

=> file reg

COST IN U.S. DOLLARS

SINCE FILE TOTAL ENTRY SESSION 0.21 0.21

FULL ESTIMATED COST

FILE 'REGISTRY' ENTERED AT 15:27:25 ON 01 OCT 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 American Chemical Society (ACS)

Property values tagged with IC are from the ZIC/VINITI data file provided by InfoChem.

STRUCTURE FILE UPDATES: 29 SEP 2003 HIGHEST RN 595542-94-2 DICTIONARY FILE UPDATES: 29 SEP 2003 HIGHEST RN 595542-94-2

TSCA INFORMATION NOW CURRENT THROUGH JULY 14, 2003

Please note that search-term pricing does apply when conducting SmartSELECT searches.

Crossover limits have been increased. See HELP CROSSOVER for details.

Experimental and calculated property data are now available. See HELP PROPERTIES for more information. See STNote 27, Searching Properties in the CAS Registry File, for complete details: http://www.cas.org/ONLINE/STN/STNOTES/stnotes27.pdf

=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END):end

=> screen 2067

SCREEN CREATED Ll

Uploading C:\Program Files\Stnexp\Queries\09963465-2.str

STRUCTURE UPLOADED L_2

=> que L2 AND L1

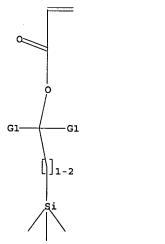
QUE L2 AND L1 L3

=> d

L3 HAS NO ANSWERS

Ll SCR 2067 L2

STR



Ak

G1 H, [@1]

Structure attributes must be viewed using STN Express query preparation. QUE ABB=ON PLU=ON L2 AND L1

=> s 13 sss sam SAMPLE SEARCH INITIATED 15:28:13 FILE 'REGISTRY' SAMPLE SCREEN SEARCH COMPLETED - 321 TO ITERATE

100.0% PROCESSED 321 ITERATIONS SEARCH TIME: 00.00.01

8 ANSWERS

FULL FILE PROJECTIONS: ONLINE **COMPLETE**

BATCH

COMPLETE

PROJECTED ITERATIONS:

5346 TO 7494

PROJECTED ANSWERS:

8 TO 329

8 SEA SSS SAM L2 AND L1

=> d

ANSWER 1 OF 8 REGISTRY COPYRIGHT 2003 ACS on STN

RN355138-88-4 REGISTRY

2-Propenoic acid, 2,3,3-trifluoro-, tetrahydro-2-oxo-3-furanyl ester, CN polymer with 2-(trimethylsilyl)propyl 2,3,3-trifluoro-2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

2-Propenoic acid, 2,3,3-trifluoro-, 2-(trimethylsily1)propyl ester, CN

polymer with tetrahydro-2-oxo-3-furanyl 2,3,3-trifluoro-2-propenoate (9CI)

MF (C9 H15 F3 O2 Si . C7 H5 F3 O4)x

CI

PCT Polyacrylic, Polyester, Polyester formed, Polyvinyl

SR CA

LC STN Files: CA, CAPLUS

> CM 1

CRN 355138-87-3 CMF C9 H15 F3 O2 Si

$$\begin{array}{c|c} \operatorname{SiMe_3} & \operatorname{O} & \operatorname{CF_2} \\ & \parallel & \parallel \\ \operatorname{Me-CH-CH_2-O-C-C-F} \end{array}$$

CM

CRN 355138-83-9 CMF C7 H5 F3 O4

- 1 REFERENCES IN FILE CA (1907 TO DATE)
- 1 REFERENCES IN FILE CAPLUS (1907 TO DATE)

=> FIL CAPLUS HCAPLUS USPATFUL

COST IN U.S. DOLLARS

SINCE FILE ENTRY

TOTAL SESSION

FULL ESTIMATED COST

2.69

FILE 'CAPLUS' ENTERED AT 15:28:24 ON 01 OCT 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

FILE 'HCAPLUS' ENTERED AT 15:28:24 ON 01 OCT 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

FILE 'USPATFULL' ENTERED AT 15:28:24 ON 01 OCT 2003 CA INDEXING COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS) L5

27 L4

```
=> duplicates remove 15
DUPLICATE PREFERENCE IS 'CAPLUS, HCAPLUS, USPATFULL'
KEEP DUPLICATES FROM MORE THAN ONE FILE? Y/(N):n
PROCESSING COMPLETED FOR L5
            17 DUPLICATE REMOVE L5 (10 DUPLICATES REMOVED)
```

=> d 16 1-17 ibib hitstr

ANSWER 1 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 1

ACCESSION NUMBER: 2001:603578 CAPLUS

DOCUMENT NUMBER: 135:187712

TITLE: Fluorinated acrylic polymer, chemically amplified

resist using it, and its patterning

Hatakeyama, Jun; Watanabe, Atsushi; Harada, Yuji INVENTOR(S): PATENT ASSIGNEE(S): Shin-Etsu Chemical Industry Co., Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 34 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO. KIND DATE APPLICATION NO. DATE ---------JP 2001226432 A2 20010821 JP 2000-37403 20000216 PRIORITY APPLN. INFO.: JP 2000-37403 20000216

355138-88-4P RL: PNU (Preparation, unclassified); TEM (Technical or engineered material

use); PREP (Preparation); USES (Uses) (fluorinated silyl-pendent acrylic polymer for chem. amplified

pos.-working resist)

RN 355138-88-4 CAPLUS

2-Propenoic acid, 2,3,3-trifluoro-, tetrahydro-2-oxo-3-furanyl ester, CN polymer with 2-(trimethylsilyl)propyl 2,3,3-trifluoro-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 355138-87-3 CMF C9 H15 F3 O2 Si

CM

CRN 355138-83-9 CMF C7 H5 F3 O4

ANSWER 2 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 2

ACCESSION NUMBER: 2001:521143 CAPLUS

DOCUMENT NUMBER: 135:114437

TITLE:

Positive-working photoresist composition for production of electric parts such as semiconductor

substrate with contact holes

INVENTOR(S): Sato, Kenichiro; Mizutani, Kazuyoshi Fuji Photo Film Co., Ltd., Japan PATENT ASSIGNEE(S): Jpn. Kokai Tokkyo Koho, 43 pp. SOURCE:

CODEN: JKXXAF

DOCUMENT TYPE: Patent LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO. KIND DATE APPLICATION NO. DATE

```
JP 2001194789 A2 20010719
                                          JP 2000-1896
                                                           20000107
PRIORITY APPLN. INFO.:
                                        JP 2000-1896
     344575-88-8P
     RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT
     (Reactant or reagent)
        (acid-sensitive resin in pos.-working photoresist compn.)
RN
     344575-88-8 CAPLUS
     2-Propenoic acid, 2-methyl-, tetrahydro-4-methyl-2-oxo-2H-pyran-4-yl
CN
     ester, polymer with 2-(trimethylsilyl)ethyl 2-propenoate (9CI) (CA INDEX
     NAME)
     CM
         1
     CRN 177080-66-9
     CMF C10 H14 O4
     CM
         131494-24-1
     CRN
     CMF C8 H16 O2 Si
Me3Si-CH2-CH2
                    - cн== cн<sub>2</sub>
    ANSWER 3 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 3
                        2001:523649 CAPLUS
ACCESSION NUMBER:
DOCUMENT NUMBER:
                         135:114440
TITLE:
                         Positive-working chemically amplified photoresist
                        composition
INVENTOR(S):
                        Sato, Kenichiro; Mizutani, Kazuyoshi
PATENT ASSIGNEE(S):
                        Fuji Photo Film Co., Ltd., Japan
                        Jpn. Kokai Tokkyo Koho, 45 pp.
SOURCE:
                        CODEN: JKXXAF
DOCUMENT TYPE:
                        Patent
LANGUAGE:
                         Japanese
FAMILY ACC. NUM. COUNT:
PATENT INFORMATION:
     PATENT NO.
                     KIND DATE
                                          APPLICATION NO. DATE
     JP 2001194788
                      A2 20010719
                                          JP 2000-1895
                                                           20000107
                                       JP 2000-1895
PRIORITY APPLN. INFO.:
                                                           20000107
    344575-88-8P
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (acid-sensitive resin in pos.-working chem. amplified photoresist
        compn.)
RN
    344575-88-8 CAPLUS
     2-Propenoic acid, 2-methyl-, tetrahydro-4-methyl-2-oxo-2H-pyran-4-yl
     ester, polymer with 2-(trimethylsilyl)ethyl 2-propenoate (9CI) (CA INDEX
     NAME)
     CM 1
```

CRN 177080-66-9 CMF C10 H14 O4

CRN 131494-24-1 CMF C8 H16 O2 Si

L6 ANSWER 4 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 4

ACCESSION NUMBER: DOCUMENT NUMBER:

2001:521142 CAPLUS

135:114436

TITLE:

Positive-working photoresist composition for

semiconductor device fabrication

PATENT ASSIGNEE(S): SOURCE:

Sato, Kenichiro; Mizutani, Kazuyoshi Fuji Photo Film Co., Ltd., Japan Jpn. Kokai Tokkyo Koho, 52 pp.

CODEN: JKXXAF

DOCUMENT TYPE:

INVENTOR(S):

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO. KIND DATE APPLICATION NO. DATE JP 2001194787 A2 JP 2000-1894 20010719 20000107 PRIORITY APPLN. INFO.: JP 2000-1894 20000107

344575-88-8P

RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT (Reactant or reagent)

(acid-sensitive resin in pos.-working photoresist compn.)

344575-88-8 CAPLUS

2-Propenoic acid, 2-methyl-, tetrahydro-4-methyl-2-oxo-2H-pyran-4-yl ester, polymer with 2-(trimethylsilyl)ethyl 2-propenoate (9CI) (CA INDEX NAME)

CM

CRN 177080-66-9 CMF C10 H14 O4

CM

CRN 131494-24-1 CMF C8 H16 O2 Si

ANSWER 5 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 5 ACCESSION NUMBER: 2001:451204 CAPLUS

DOCUMENT NUMBER:

135:53506

TITLE: INVENTOR(S): Positive-working photoresist composition

PATENT ASSIGNEE(S):

Mizutani, Kazuyoshi; Sato, Kenichiro Fuji Photo Film Co., Ltd., Japan Jpn. Kokai Tokkyo Koho, 30 pp.

SOURCE: CODEN: JKXXAF

DOCUMENT TYPE: LANGUAGE:

Patent Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO. KIND DATE APPLICATION NO. DATE JP 2001166482 A2 20010622 -----JP 1999-350506 19991209 20010622 JP 1999-350506

PRIORITY APPLN. INFO.: 344575-88-8P

RL: SPN (Synthetic preparation); TEM (Technical or engineered material

use); PREP (Preparation); USES (Uses)

(pos.-working photoresist compn. contg. polymer with lactone structure)

RN 344575-88-8 CAPLUS

CN 2-Propenoic acid, 2-methyl-, tetrahydro-4-methyl-2-oxo-2H-pyran-4-yl ester, polymer with 2-(trimethylsilyl)ethyl 2-propenoate (9CI) (CA INDEX

CM 1

CRN 177080-66-9 CMF C10 H14 O4

$$\begin{array}{c|c} H_2C & Me \\ \hline \\ Me-C-C-O \\ \hline \\ O \\ \end{array}$$

CRN 131494-24-1 CMF C8 H16 O2 Si

$$0$$
 || Me₃Si-CH₂-CH₂-O-C-CH= CH₂

ANSWER 6 OF 17 USPATFULL on STN

ACCESSION NUMBER:

2001:102902 USPATFULL

TITLE:

Curable composition for top coating and articles coated

therewith

INVENTOR(S):

Inoue, Masaharu, Kobe, Japan Kono, Yoshiyuki, Akashi, Japan Nakamura, Seigo, Takasago, Japan Nanbu, Toshiro, Kobe, Japan

PATENT ASSIGNEE(S):

Kaneka Corporation, Osaka, Japan (non-U.S. corporation)

NUMBER KIND DATE ------PATENT INFORMATION: US 6255392 B1 20010703 WO 9818873 19980507 US 1999-297385 APPLICATION INFO.: 19990430 (9) WO 1997-JP3942 19971029

19990430 PCT 371 date 19990430 PCT 102(e) date

NUMBER DATE

Leydig, Voit & Mayer, Ltd.

PRIORITY INFORMATION: JP 1996-290835 19961031

DOCUMENT TYPE: Utility FILE SEGMENT:

GRANTED

PRIMARY EXAMINER: Dawson, Robert ASSISTANT EXAMINER: Robertson, Jeffrey B.

NUMBER OF CLAIMS: EXEMPLARY CLAIM: 1

LEGAL REPRESENTATIVE:

LINE COUNT:

1403

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

IT 206749-24-8P

(curable compns. for top coating and articles coated therewith with excellent acid and mar resistance, appearance and heat curing properties, useful for automobiles)

RN 206749-24-8 USPATFULL

CN 2-Propenoic acid, 2-methyl-, cyclohexyl ester, polymer with ethenylbenzene, 2-ethylhexyl 2-propenoate, 2-[[(3-hydroxy-2,2-dimethylpropoxy)carbonyl]oxy]ethyl 2-propenoate, 2-hydroxyethyl 2-methyl-2-propenoate and 3-(trimethylsilyl)propyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 182002-51-3 CMF C11 H18 O6

CM 2

CRN 16085-37-3 CMF C10 H20 O2 Si

$$\begin{array}{c} \text{O } \text{CH}_2 \\ || & || \\ \text{Me}_3 \text{Si} - \text{(CH}_2)_3 - \text{O} - \text{C} - \text{C} - \text{Me} \end{array}$$

CM 3

CRN 868-77-9 CMF C6 H10 O3

CM 4

CRN 103-11-7 CMF C11 H20 O2

CM 5

CRN 101-43-9 CMF C10 H16 O2

```
CM
      6
```

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

ANSWER 7 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 6

ACCESSION NUMBER:

1998:293575 CAPLUS

DOCUMENT NUMBER:

128:322943

TITLE:

Curable compositions for top coating and articles coated therewith with excellent acid and mar resistance, appearance and heat curing properties,

useful for automobiles

INVENTOR(S):

Inoue, Masaharu; Kono, Yoshiyuki; Nakamura, Seigo;

Nanbu, Toshiro

CODEN: PIXXD2

PATENT ASSIGNEE(S):

Kaneka Corp., Japan; Inoue, Masaharu; Kono, Yoshiyuki;

Nakamura, Seigo; Nanbu, Toshiro PCT Int. Appl., 61 pp.

SOURCE:

DOCUMENT TYPE:

Patent

LANGUAGE:

Japanese

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 9818873 W: US	A1	19980507	WO 1997-JP3942	19971029
RW: BE, DE,	FR, GB	, IT		
JP 10183052	A2	19980707	JP 1997-295970	19971028
EP 936260	A1	19990818	EP 1997-909686	19971029
R: BE, DE,	FR			
US 6255392	B1	20010703	US 1999-297385	19990430
PRIORITY APPLN. INFO.	:		JP 1996-290835 A	19961031
•			WO 1997-JP3942 W	19971029

IT 206749-24-8P

RL: IMF (Industrial manufacture); POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(curable compns. for top coating and articles coated therewith with excellent acid and mar resistance, appearance and heat curing properties, useful for automobiles) 206749-24-8 CAPLUS

RN

CN

2-Propenoic acid, 2-methyl-, cyclohexyl ester, polymer with ethenylbenzene, 2-ethylhexyl 2-propenoate, 2-[[(3-hydroxy-2,2dimethylpropoxy) carbonyl]oxy]ethyl 2-propenoate, 2-hydroxyethyl 2-methyl-2-propenoate and 3-(trimethylsilyl)propyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM

CRN 182002-51-3 CMF C11 H18 O6

CM 2

CRN 16085-37-3 C10 H20 O2 Si

CRN 868-77-9 CMF C6 H10 O3

CM

CRN 103-11-7 CMF C11 H20 O2

CM 5

CRN 101-43-9 CMF C10 H16 O2

CM

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

REFERENCE COUNT:

THERE ARE 4 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

ANSWER 8 OF 17 USPATFULL on STN

ACCESSION NUMBER:

97:86398 USPATFULL

TITLE:

Electrophotographic material for color proofing

INVENTOR(S): Kato, Eiichi, Shizuoka, Japan Osawa, Sadao, Shizuoka, Japan

PATENT ASSIGNEE(S):

Fuji Photo Film Co., Ltd., Kanagawa, Japan (non-U.S.

corporation)

NUMBER KIND DATE PATENT INFORMATION: US 5670283 19970923 US 1994-279068 19940722 (8)

APPLICATION INFO.: RELATED APPLN. INFO.:

Continuation of Ser. No. US 1992-952941, filed on 28

Sep 1992, now abandoned

NUMBER DATE PRIORITY INFORMATION: JP 1991-249819 19910927 JP 1991-259430 19911007 JP 1991-289648 19911106 JP 1991-289649 19911106 Utility

DOCUMENT TYPE:

FILE SEGMENT: Granted

PRIMARY EXAMINER: Rodee, Christopher D.

Sughrue, Mion, Zinn, Macpeak & Seas, PLLC LEGAL REPRESENTATIVE:

NUMBER OF CLAIMS: 5

EXEMPLARY CLAIM:

NUMBER OF DRAWINGS: 2 Drawing Figure(s); 1 Drawing Page(s) LINE COUNT:

4445

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

IT 150625-94-8P 150773-30-1P

(prepn. and use of, in electrophotog. plate, for reduced tack)

RN 150625-94-8 USPATFULL

CN 2-Propenoic acid, 2-methyl-, 2,2,3,3,4,4-hexafluorobutyl ester, polymer
 with methyl 2-methyl-2-propenoate, methyl 2-propenoate, oxiranylmethyl
 2-methyl-2-propenoate, 2,2,3,3-tetrafluoropropyl 2-methyl-2-propenoate
 and 3-[tris(trifluoromethyl)silyl]propyl 2-methyl-2-propenoate, block,
 graft (9CI) (CA INDEX NAME)

CM 1

CRN 150625-93-7 CMF C10 H11 F9 O2 Si

CM 2

CRN 45168-50-1 CMF C8 H8 F6 O2

$$\begin{array}{c|c} & \text{O} & \text{CH}_2 \\ \parallel & \parallel \\ \text{F}_2\text{CH}-\text{CF}_2-\text{CF}_2-\text{CH}_2-\text{O}-\text{C}-\text{C}-\text{Me} \end{array}$$

CM 3

CRN 45102-52-1 CMF C7 H8 F4 O2

$$\begin{array}{c} \text{O} \quad \text{CH}_2 \\ \parallel \quad \parallel \\ \text{F}_2\text{CH}-\text{CF}_2-\text{CH}_2-\text{O}-\text{C}-\text{C}-\text{Me} \end{array}$$

CM 4

CRN 106-91-2 CMF C7 H10 O3

$$\overset{\text{O}}{\longleftarrow} \overset{\text{O}}{\underset{\text{CH}_2-\text{O}-\text{C}-\text{C}-\text{Me}}{\text{Me}}}$$

CM 5

CRN 96-33-3 CMF C4 H6 O2

CM 6

CRN 80-62-6 CMF C5 H8 O2

H₂C 0 150773-30-1 USPATFULL RN2-Propenoic acid, 2-methyl-, 3-[dimethyl(nonafluorobutyl)silyl]propyl ester, polymer with methyl 2-methyl-2-propenoate polymer with oxiranylmethyl 2-methyl-2-propenoate 2-methyl-2-propenoate and oxydi-2,1-ethanediyl di-2-propenoate (9CI) (CA INDEX NAME) CM 1 CRN 150773-29-8 CMF C13 H17 F9 O2 Si O CH₂ (CF2)3-CF3 $(CH_2)_3 - 0$ Me CM CRN 4074-88-8 CMF C10 H14 O5 O-CH2-CH2-O-CH2-CH2-O-C-CH=CH2 CM 3 CRN 79468-88-5 (C7 H10 O3 . C5 H8 O2)x . x C4 H6 O2 CMF CDES 8:GD, ESTER CM4 CRN 79-41-4 CMF C4 H6 O2 СH₂ Me-C-CO2H CM 5 CRN 26141-88-8 (C7 H10 O3 . C5 H8 O2)x CMF CCI PMS

CM

6 CRN 106-91-2 CMF C7 H10 O3

CRN 80-62-6 CMF C5 H8 O2

H₂C Me-C-C-OMe

ANSWER 9 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 7

ACCESSION NUMBER:

1993:637954 CAPLUS

DOCUMENT NUMBER:

119:237954

TITLE:

Electrophotographic material for color proofing

INVENTOR(S):

Kato, Eiichi; Osawa, Sadao Fuji Photo Film Co., Ltd., Japan

PATENT ASSIGNEE(S):

Eur. Pat. Appl., 165 pp.

SOURCE:

CODEN: EPXXDW

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT: PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
EP 534479	A1	19930331	EP 1992-116494	19920925
EP 534479	B1	19981209		
R: DE, GB				
JP 05197169	A2	19930806	JP 1992-310754	19920928
US 5670283	Α	19970923	US 1994-279068	19940722
PRIORITY APPLN. INFO.	:		JP 1991-249819	19910927
			JP 1991-259430	19911007
			JP 1991-289648	19911106
			JP 1991-289649	19911106
			US 1992-952941	19920928

IT 150625-94-8P 150773-30-1P

RL: SPN (Synthetic preparation); PREP (Preparation)

(prepn. and use of, in electrophotog. plate, for reduced tack)

RN 150625-94-8 CAPLUS

2-Propenoic acid, 2-methyl-, 2,2,3,3,4,4-hexafluorobutyl ester, polymer with methyl 2-methyl-2-propenoate, methyl 2-propenoate, oxiranylmethyl 2-methyl-2-propenoate, 2,2,3,3-tetrafluoropropyl 2-methyl-2-propenoate and 3-[tris(trifluoromethyl)silyl]propyl 2-methyl-2-propenoate, block, graft (9CI) (CA INDEX NAME)

CM 1

CRN 150625-93-7 C10 H11 F9 O2 Si

CM 2

CRN 45168-50-1 CMF C8 H8 F6 O2

$$\begin{array}{c|c} & \text{O} & \text{CH}_2 \\ \parallel & \parallel \\ \text{F}_2\text{CH}-\text{CF}_2-\text{CF}_2-\text{CH}_2-\text{O}-\text{C}-\text{C}-\text{Me} \end{array}$$

3 CM

CRN 45102-52-1 CMF C7 H8 F4 O2

CRN 106-91-2 CMF C7 H10 O3

CM 5

CRN 96-33-3 CMF C4 H6 O2

CM 6

CRN 80-62-6 CMF C5 H8 O2

RN 150773-30-1 CAPLUS
CN 2-Propenoic acid, 2-methyl-, 3-[dimethyl(nonafluorobutyl)silyl]propyl ester, polymer with methyl 2-methyl-2-propenoate polymer with oxiranylmethyl 2-methyl-2-propenoate 2-methyl-2-propenoate and oxydi-2,1-ethanediyl di-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 150773-29-8 CMF C13 H17 F9 O2 Si

CM 2

CRN 4074-88-8 CMF C10 H14 O5

$$\begin{array}{c} {\rm O} \\ || \\ {\rm H}_2{\rm C} = {\rm CH} - {\rm C} - {\rm O} - {\rm CH}_2 - {\rm CH}_2 - {\rm O} - {\rm CH}_2 - {\rm CH}_2 - {\rm O} - {\rm C} - {\rm CH} = {\rm CH}_2 \\ \end{array}$$

CM 3

CRN 79468-88-5 CMF (C7 H10 O3 . C5 H8 O2)x . x C4 H6 O2

CM 4

CRN 79-41-4 CMF C4 H6 O2

$$^{\rm CH_2}_{||}_{\rm Me-C-CO_2H}$$

CRN 26141-88-8

(C7 H10 O3 . C5 H8 O2)xCMF

CCI PMS

> CM 6

CRN 106-91-2 CMF C7 H10 O3

CM

CRN 80-62-6 CMF C5 H8 O2

ANSWER 10 OF 17 USPATFULL on STN

ACCESSION NUMBER: 91:106413 USPATFULL

TITLE: Vinylidene fluoride copolymer and process for producing

the same

INVENTOR(S):

Watanabe, Junichi, Ageo, Japan Yamamoto, Yasushi, Takasaki, Japan

PATENT ASSIGNEE(S): Shin-Etsu Chemical Co., Ltd., Tokyo, Japan (non-U.S.

corporation)

NUMBER KIND DATE ---------PATENT INFORMATION: US 5077362 19911231 APPLICATION INFO.: US 1990-499975 19900327 (7)

> NUMBER DATE

PRIORITY INFORMATION: JP 1989-76348 19890328 JP 1989-76349 19890328

DOCUMENT TYPE: Utility FILE SEGMENT: Granted

PRIMARY EXAMINER: Schofer, Joseph L.

ASSISTANT EXAMINER: Sarofim, N.

LEGAL REPRESENTATIVE: Oblon, Spivak, McClelland, Maier & Neustadt

NUMBER OF CLAIMS: 11 EXEMPLARY CLAIM: 1 LINE COUNT: 365

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

IT 131272-45-2P

(films and coatings, weather- and chem. resistant, prepn. of)

RN 131272-45-2 USPATFULL

2-Propenoic acid, 2-methyl-, 3-(triethenylsilyl)propyl ester, polymer with 1,1-difluoroethene (9CI) (CA INDEX NAME) CN

CM

CRN 131272-44-1 CMF C13 H20 O2 Si

$$\begin{array}{c|cccc} {\rm H}_2{\rm C} & {\rm O} & {\rm CH} \begin{array}{c} {\rm CH}_2 \\ \parallel & \parallel & \parallel \\ {\rm Me} - {\rm C} - {\rm C} - {\rm O} - \left({\rm CH}_2 \right)_3 - {\rm Si} - {\rm CH} \begin{array}{c} {\rm CH}_2 \\ \parallel & \parallel \\ {\rm CH} \begin{array}{c} {\rm CH}_2 \end{array} \end{array}$$

CRN 75-38-7 CMF C2 H2 F2

CH₂ || F- C- F

L6 ANSWER 11 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 8

ACCESSION NUMBER:

1991:24806 CAPLUS

DOCUMENT NUMBER:

114:24806

TITLE:

Vinylidene fluoride-unsaturated silane copolymer

manufacture

INVENTOR(S):

Watanabe, Junichi; Yamamoto, Yasushi Shin-Etsu Chemical Co., Ltd., Japan

PATENT ASSIGNEE(S): SOURCE:

Eur. Pat. Appl., 8 pp. CODEN: EPXXDW

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
EP 390078	A1	19901003	EP 1990-105825	19900327
EP 390078	B1	19930623		
R: DE, FR,	GB			
JP 02252713	A2	19901011	JP 1989-76348	19890328
JP 08005937	B4	19960124		
JP 02252714	A2	19901011	JP 1989-76349	19890328
US 5077362	Α	19911231	US 1990-499975	19900327
PRIORITY APPLN. INFO	. :		JP 1989-76348	19890328
			JP 1989-76349	19890328

IT 131272-45-2P

RL: PREP (Preparation)

(films and coatings, weather- and chem. resistant, prepn. of)

RN 131272-45-2 CAPLUS

CN 2-Propenoic acid, 2-methyl-, 3-(triethenylsilyl)propyl ester, polymer with 1,1-difluoroethene (9CI) (CA INDEX NAME)

CM 1

CRN 131272-44-1 CMF C13 H20 O2 Si

CM 2

CRN 75-38-7 CMF C2 H2 F2

CH₂ || F- C- F

L6 ANSWER 12 OF 17 USPATFULL on STN ACCESSION NUMBER: 89:99030 USPATFULL

TITLE: Silymethylene methacrylate contact lens and polymer INVENTOR(S): Foley, Jr., William M., Glendale, CA, United States PATENT ASSIGNEE(S): John D. McCarry, Santa Ana, CA, United States (U.S. corporation) NUMBER KIND DATE PATENT INFORMATION: US 4886864 19891212 APPLICATION INFO.: US 1988-246419 19880919 (7) Division of Ser. No. US 1985-61477, filed on 1 Jun RELATED APPLN. INFO.: 1985, now patented, Pat. No. US 4780516 Continuation-in-part of Ser. No. US 1985-742122, filed on 5 Jun 1985, now abandoned Continuation-in-part of Ser. No. US 1984-641594, filed on 17 Aug 1984, now abandoned DOCUMENT TYPE: Utility FILE SEGMENT: Granted PRIMARY EXAMINER: Schofer, Joseph L. ASSISTANT EXAMINER: Walker, Alex H. LEGAL REPRESENTATIVE: Hubbard, Grant L. NUMBER OF CLAIMS: 8 EXEMPLARY CLAIM: 1 LINE COUNT: 366 CAS INDEXING IS AVAILABLE FOR THIS PATENT. IT 104764-11-6 (contact lens prepn. from) RN 104764-11-6 USPATFULL 2-Propenoic acid, 2-methyl-, 3-[tris[[(methoxymethyl)dimethylsilyl]methyl] silyl]propyl ester, homopolymer (9CI) (CA INDEX NAME) CM CRN 104764-10-5 CMF C22 H50 O5 Si4 MeO-CH2 siо сн₂ Me Me $MeO-CH_2-Si-CH_2-Si-(CH_2)_3-O-C-C-Me$ Me Me MeO-CH2-Si-CH2 Me ANSWER 13 OF 17 USPATFULL on STN ACCESSION NUMBER: 89:30178 USPATFULL TITLE: Gas permeable contact lens and method and materials for its manufacture INVENTOR(S): Chen, Richard Y. S., Raleigh, NC, United States PATENT ASSIGNEE(S): Ocular Technologies, Inc., Raleigh, NC, United States (U.S. corporation) NUMBER KIND DATE -----PATENT INFORMATION: US 4822864 19890418 APPLICATION INFO.: US 1988-241190 19880907 (7) RELATED APPLN. INFO.: Continuation of Ser. No. US 1987-63312, filed on 18 Jun 1987 DOCUMENT TYPE: Utility FILE SEGMENT: Granted

PRIMARY EXAMINER: Foelak, Morton LEGAL REPRESENTATIVE: Eslinger, Lewis H. NUMBER OF CLAIMS: EXEMPLARY CLAIM: NUMBER OF DRAWINGS: 4 Drawing Figure(s); 1 Drawing Page(s) LINE COUNT: 344 CAS INDEXING IS AVAILABLE FOR THIS PATENT. IT 123538-02-3 (oxygen permeable hard contact lenses contg.) RN 123538-02-3 USPATFULL 2-Propenoic acid, 2-methyl-, polymer with 1,2-ethanediyl bis(2-methyl-2-propenoate), [2-[3(or 4)-ethenylphenyl]ethyl]trimethoxysi CN lane, 2-hydroxypropyl 2-methyl-2-propenoate, methyl 2-methyl-2propenoate, trimethylsilyl 2-methyl-2-propenoate and
3-(trimethylsilyl)propyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 119181-19-0 CMF C13 H20 O3 Si CCI IDS CDES *

 $D1-CH=CH_2$

$$\begin{array}{c} \text{OMe} \\ | \\ \text{MeO-Si-CH}_2\text{-CH}_2\text{-D1} \\ | \\ \text{OMe} \end{array}$$

CM 2

CRN 16085-37-3 CMF C10 H20 O2 Si

CM 3

CRN 13688-56-7 CMF C7 H14 O2 Si

$$\begin{array}{c} \text{O} \quad \text{CH}_2 \\ \parallel \quad \parallel \\ \text{Me}_3 \text{Si} - \text{O} - \text{C} - \text{C} - \text{Me} \end{array}$$

CM 4

CRN 923-26-2 CMF C7 H12 O3

CM 5

CRN 97-90-5 CMF C10 H14 O4

CM 6

CRN 80-62-6

CRN 79-41-4 CMF C4 H6 O2

```
H<sub>2</sub>C
Me-C-C-OMe
       CM
              7
```

CH₂ Me-C-CO2H

ANSWER 14 OF 17 USPATFULL on STN ACCESSION NUMBER: 89:27949 USPATFULL

TITLE:

Gas permeable contact lens and method and materials for its manufacture

INVENTOR(S): Chen, Richard Y. S., Raleigh, NC, United States PATENT ASSIGNEE(S): Ocular Technologies, Inc., Raleigh, NC, United States

(U.S. corporation)

NUMBER KIND DATE PATENT INFORMATION: US 4820747 19890411

APPLICATION INFO.: US 1988-241191 19880907 (7)

Continuation of Ser. No. US 1987-63312, filed on 18 Jun RELATED APPLN. INFO.:

1987 DOCUMENT TYPE: Utility

FILE SEGMENT: Granted PRIMARY EXAMINER:

Foelak, Morton LEGAL REPRESENTATIVE: Eslinger, Lewis H. NUMBER OF CLAIMS: 9

EXEMPLARY CLAIM:

NUMBER OF DRAWINGS: 4 Drawing Figure(s); 1 Drawing Page(s) LINE COUNT:

360 CAS INDEXING IS AVAILABLE FOR THIS PATENT.

IT 123538-02-3

(oxygen permeable hard contact lenses contg.)

123538-02-3 USPATFULL ŔN

2-Propenoic acid, 2-methyl-, polymer with 1,2-ethanediyl bis(2-methyl-2-propenoate), [2-[3(or 4)-ethenylphenyl]ethyl]trimethoxysi lane, 2-hydroxypropyl 2-methyl-2-propenoate, methyl 2-methyl-2propenoate, trimethylsilyl 2-methyl-2-propenoate and 3-(trimethylsilyl)propyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 119181-19-0 CMF C13 H20 O3 Si CCI IDS CDES *



D1-CH=CH2

$$\begin{array}{c} \text{OMe} \\ | \\ \text{MeO-Si-CH}_2\text{-CH}_2\text{-D1} \\ | \\ \text{OMe} \end{array}$$

CRN 16085-37-3 CMF C10 H20 O2 Si

$$\begin{array}{c} \text{O} \quad \text{CH}_2 \\ || \quad || \\ \text{Me}_3 \text{Si-} \left(\text{CH}_2\right)_3 - \text{O-} \text{C-} \text{C-} \text{Me} \end{array}$$

CM 3

CRN 13688-56-7 CMF C7 H14 O2 Si

CM

CRN 923-26-2 CMF C7 H12 O3

CM 5

CRN 97-90-5 CMF C10 H14 O4

CM 6

· CRN 80-62-6 CMF C5 H8 O2

7 CM

CRN 79-41-4 CMF C4 H6 O2

L6 ANSWER 15 OF 17 USPATFULL on STN ACCESSION NUMBER:

TITLE:

89:19319 USPATFULL Gas permeable contact lens and method and materials for

its manufacture

INVENTOR(S): PATENT ASSIGNEE(S):

Chen, Richard Y. S., Raleigh, NC, United States Ocular Technologies, Inc., Raleigh, NC, United States

KIND

(U.S. corporation)

NUMBER

DATE

```
PATENT INFORMATION:
                       US 4812598
                                              19890314
APPLICATION INFO.:
                         US 1987-63312
DOCUMENT TYPE:
                          Utility
FILE SEGMENT:
                          Granted
PRIMARY EXAMINER:
                          Foelak, Morton
LEGAL REPRESENTATIVE:
                          Eslinger, Lewis H.
NUMBER OF CLAIMS:
EXEMPLARY CLAIM:
NUMBER OF DRAWINGS:
                          4 Drawing Figure(s); 1 Drawing Page(s)
LINE COUNT:
                          346
CAS INDEXING IS AVAILABLE FOR THIS PATENT.
IT 123538-02-3
         (oxygen permeable hard contact lenses contg.)
RN
     123538-02-3 USPATFULL
     2-Propenoic acid, 2-methyl-, polymer with 1,2-ethanediyl
       bis(2-methyl-2-propenoate), [2-[3(or 4)-ethenylphenyl]ethyl)trimethoxysi lane, 2-hydroxypropyl 2-methyl-2-propenoate, methyl 2-methyl-2-
        propenoate, trimethylsilyl 2-methyl-2-propenoate and
        3-(trimethylsilyl)propyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)
     CM
           1
     CRN 119181-19-0
     CMF C13 H20 O3 Si
CCI IDS
     CDES *
    D1-CH=CH2
     OMe
MeO-Si-CH_2-CH_2-D1
     OMe
     CM
     CRN 16085-37-3
     CMF C10 H20 O2 Si
                  о сн<sub>2</sub>
Me_3Si-(CH_2)_3-O-C-C-Me
     CM
          3
     CRN 13688-56-7
     CMF C7 H14 O2 Si
          о сн<sub>2</sub>
Me3Si-O-C-C-Me
     CM
     CRN 923-26-2
     CMF C7 H12 O3
```

о сн₂

 $Me-CH-CH_2-O-C-C-Me$

ОН

CRN 97-90-5 CMF C10 H14 O4

CM 6

CRN 80-62-6 CMF C5 H8 O2

7 CM

CRN 79-41-4 CMF C4 H6 O2

$$^{\rm CH_2}_{||}_{\rm Me-C-CO_2H}$$

ANSWER 16 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 9

ACCESSION NUMBER: 1989:601674 CAPLUS

DOCUMENT NUMBER:

111:201674 TITLE:

Crosslinked siloxane-acrylate copolymers, a method for

their manufacture, and hard oxygen-permeable contact

lenses containing them

INVENTOR(S): Chen, Richard Y. S.

PATENT ASSIGNEE(S): Ocular Technologies, Inc., USA

SOURCE: Eur. Pat. Appl., 18 pp.

CODEN: EPXXDW Patent

DOCUMENT TYPE:

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE			
	EP 295947		19881221		19880617			
	EP 295947	A3	19891213					
	EP 295947	B1	19941221					
	R: AT, CH,	DE, ES	, FR, GB, IT	, LI, SE				
•	US 4812598	Α	19890314	US 1987-63312	19870618			
	BR 8802917	A	19890103	BR 1988-2917	19880615			
	AU 8818125	A1	19890119	AU 1988-18125	19880617			
	JP 01099021	A2	19890417	JP 1988-149906	19880617			
	ES 2068200	T 3	19950416	ES 1988-305563	19880617			
	US 4820747	Α	19890411	US 1988-241191	19880907			
	US 4822864	Α	19890418	US 1988-241190	19880907			
PRIC	RITY APPLN. INFO.	. :		US 1987-63312	19870618			
IT	123538-02-3							
	RL: BIOL (Biolog	gical s	tudy)					
	(oxygen perme	eable h	ard contact	lenses contg.)				
RN	123538-02-3 CA	PLUS						
CN	CN 2-Propenoic acid, 2-methyl-, polymer with 1,2-ethanediyl							
	bis(2-methyl-2-propenoate), [2-[3(or 4)-ethenylphenyl]ethyl]trimethoxysila							
	ne, 2-hydroxypropyl 2-methyl-2-propenoate, methyl 2-methyl-2-propenoate,							
	trimethylsilyl 2-methyl-2-propenoate and 3-(trimethylsilyl)propyl							
	2-methyl-2-propenoate (9CI) (CA INDEX NAME)							

CRN 119181-19-0 CMF C13 H20 O3 Si CCI IDS



 $D1-CH=CH_2$

$$\begin{array}{c} \text{OMe} \\ | \\ \text{MeO-Si-CH}_2\text{-CH}_2\text{-D1} \\ | \\ \text{OMe} \end{array}$$

CM 2

CRN 16085-37-3 CMF C10 H20 O2 Si

. CM 3

CRN 13688-56-7 CMF C7 H14 O2 Si

$$\begin{array}{c|c} \text{O} & \text{CH}_2 \\ \parallel & \parallel \\ \text{Me}_3 \text{Si} - \text{O} - \text{C} - \text{C} - \text{Me} \end{array}$$

CM 4

CRN 923-26-2 CMF C7 H12 O3

CM 5

CRN 97-90-5 CMF C10 H14 O4

CM 6

CRN 80-62-6 CMF C5 H8 O2

$$\begin{array}{c|c} ^{H_2C} & o \\ \parallel & \parallel \\ \text{Me-} & C- & C- & OMe \end{array}$$

CRN 79-41-4 CMF C4 H6 O2

ÇH2

ANSWER 17 OF 17 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 10

ACCESSION NUMBER:

1986:578487 CAPLUS

DOCUMENT NUMBER:

105:178487

TITLE:

Contact lenses comprising alkylsilane polymers

INVENTOR(S):

Foley, William M.

PATENT ASSIGNEE(S):

McCarry, John D., USA PCT Int. Appl., 51 pp.

SOURCE:

CODEN: PIXXD2

DOCUMENT TYPE:

Patent

LANGUAGE:

English

FAMILY ACC. NUM. COUNT:

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 8601219	A1	19860227	WO 1985-US1522	19850808
RW: AT, BE,	CH, DE	, FR, GB,	IT, LU, NL, SE	
EP 194277	A1	19860917	EP 1985-904314	19850808
R: AT, BE,	CH, DE	, FR, GB,	IT, LI, LU, NL, SE	
CA 1258343	A1	19890808	CA 1985-488838	19850816
PRIORITY APPLN. INFO	.:		US 1984-641594	19840817
			US 1985-742122	19850605

IT 104764-11-6

RL: THU (Therapeutic use); BIOL (Biological study); USES (Uses)

(contact lens prepn. from)

RN 104764-11-6 CAPLUS

2-Propenoic acid, 2-methyl-, 3-[tris[[(methoxymethyl)dimethylsilyl]methyl] silyl]propyl ester, homopolymer (9CI) (CA INDEX NAME)

CM

CRN 104764-10-5 CMF C22 H50 O5 Si4

Please note that search-term pricing does apply when conducting SmartSELECT searches.

Crossover limits have been increased. See HELP CROSSOVER for details.

Experimental and calculated property data are now available. See HELP PROPERTIES for more information. See STNote 27, Searching Properties in the CAS Registry File, for complete details: http://www.cas.org/ONLINE/STN/STNOTES/stnotes27.pdf

=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END): end

Uploading C:\Program Files\Stnexp\Queries\09963465-a.str

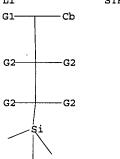
L1 STRUCTURE UPLOADED

=> que L1

QUE L1

=> d 12

L2 HAS NO ANSWERS



G1 H, Cb, Ak

G2 H, Ak

Structure attributes must be viewed using STN Express query preparation. QUE ABB=ON PLU=ON L1

=> s 12 sss sam

SAMPLE SEARCH INITIATED 18:46:04 FILE 'REGISTRY' SAMPLE SCREEN SEARCH COMPLETED - 6857 TO ITERATE

14.6% PROCESSED 1000 ITERATIONS INCOMPLETE SEARCH (SYSTEM LIMIT EXCEEDED) SEARCH TIME: 00.00.01

ONLINE **COMPLETE** FULL FILE PROJECTIONS:

BATCH **COMPLETE** PROJECTED ITERATIONS: 142102

PROJECTED ANSWERS:

132178 TO 334 TO 1036

5 SEA SSS SAM L1

=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END):end

Uploading C:\Program Files\Stnexp\Queries\09963465.str

STRUCTURE UPLOADED L4

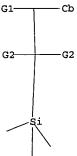
=> que L4

QUE L4 L5

5 ANSWERS

Ψ.

```
=> d
L5 HAS NO ANSWERS
L4 ST
```



G1 H,Cb,Ak G2 H,Ak

Structure attributes must be viewed using STN Express query preparation. L5 $${\tt QUE}$$ ABB=ON PLU=ON L4

=> s 15 sss sam SAMPLE SEARCH INITIATED 18:46:29 FILE 'REGISTRY' SAMPLE SCREEN SEARCH COMPLETED - 16356 TO ITERATE

6.1% PROCESSED 1000 ITERATIONS INCOMPLETE SEARCH (SYSTEM LIMIT EXCEEDED) SEARCH TIME: 00.00.01 7 ANSWERS

FULL FILE PROJECTIONS: ONLINE **COMPLETE**
BATCH **COMPLETE**

PROJECTED ITERATIONS: 319469 TO 334771
PROJECTED ANSWERS: 1648 TO 2930

L6 7 SEA SSS SAM L4

=> FIL CAPLUS HCAPLUS USPATFUL COST IN U.S. DOLLARS

SINCE FILE TOTAL ENTRY SESSION 0.80 1.01

FULL ESTIMATED COST

FILE 'CAPLUS' ENTERED AT 18:46:41 ON 01 OCT 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

FILE 'HCAPLUS' ENTERED AT 18:46:41 ON 01 OCT 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

FILE 'USPATFULL' ENTERED AT 18:46:41 ON 01 OCT 2003 CA INDEXING COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

=> s 13

L7. 10 L3

=> s 16

L8 15 L6

=> s 17 or 18

L9 25 L7 OR L8

=> duplicates remove
ENTER L# LIST OR (END):19
DUPLICATE PREFERENCE IS 'CAPLUS, HCAPLUS, USPATFULL'
KEEP DUPLICATES FROM MORE THAN ONE FILE? Y/(N):n
PROCESSING COMPLETED FOR L9
L10
13 DUPLICATE REMOVE L9 (12 DUPLICATES REMOVED)

=> s l10 and (resist or photoresist)
L11 0 L10 AND (RESIST OR PHOTORESIST)

```
=> d his
```

INVENTOR (S):

Ll

L2

1.3

L4

(FILE 'HOME' ENTERED AT 18:45:36 ON 01 OCT 2003)
FILE 'REGISTRY' ENTERED AT 18:45:42 ON 01 OCT 2003

STRUCTURE UPLOADED

STRUCTURE UPLOADED

QUE L1

5 S L2 SSS SAM

```
L5
                QUE L4
L6
              7 S L5 SSS SAM
     FILE 'CAPLUS, HCAPLUS, USPATFULL' ENTERED AT 18:46:41 ON 01 OCT 2003
L7
             10 S L3
L8
             15 S L6
             25 S L7 OR L8
L9
             13 DUPLICATE REMOVE L9 (12 DUPLICATES REMOVED)
L10
L11
              0 $ L10 AND (RESIST OR PHOTORESIST)
=> d 110 1-13 ibib hitstr
L10 ANSWER 1 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 1
ACCESSION NUMBER:
                         2003:259738 CAPLUS
DOCUMENT NUMBER:
                         138:275941
TITLE:
                         Oxidative hair dye composition containing silyl
                         substituted p-aminophenol or p-phenylenediamine
                         derivatives
INVENTOR (S):
                         Richard, Herve
                         L'Oreal, Fr.
PATENT ASSIGNEE(S):
SOURCE:
                         Eur. Pat. Appl., 18 pp.
                         CODEN: EPXXDW
DOCUMENT TYPE:
                         Patent
LANGUAGE:
                         French
FAMILY ACC. NUM. COUNT:
PATENT INFORMATION:
     PATENT NO.
                      KIND DATE
                                            APPLICATION NO. DATE
                      ----
                            -----
     EP 1298135
                      A1
                            20030402
                                            EP 2002-292148
                                                             20020830
         {\tt R:} \quad {\tt AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,} \\
             IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, SK
                                           FR 2001-12523
                            20030404
    FR 2830188
                      A1
                                                             20010928
     CN 1410048
                       Α
                            20030416
                                            CN 2002-143902
                                                             20020927
     JP 2003128526
                            20030508
                                            JP 2002-284272
                       A2
                                                             20020927
    US 2003150066
                                            US 2002-259298
                                                             20020930
                            20030814
                       A1
                                        FR 2001-12523
PRIORITY APPLN. INFO.:
                                                        A 20010928
OTHER SOURCE(S):
                         MARPAT 138:275941
    503534-45-0P
     RL: COS (Cosmetic use); SPN (Synthetic preparation); BIOL (Biological
     study); PREP (Preparation); USES (Uses)
        (oxidative hair dye compn. contg. silyl substituted aminophenol or
        phenylenediamine derivs.)
    503534-45-0 CAPLUS
RN
    1,4-Benzenediamine, 2-[2-(trimethylsilyl)ethyl]-, dihydrochloride (9CI)
CN
     (CA INDEX NAME)
  NH2
       CH_2 - CH_2 - SiMe_3
  NH<sub>2</sub>
      2 HCl
                               THERE ARE 3 CITED REFERENCES AVAILABLE FOR THIS
REFERENCE COUNT:
                         3
                               RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT
L10 ANSWER 2 OF 13 USPATFULL on STN
                        2003:216794 USPATFULL
ACCESSION NUMBER:
TITLE:
                        Dyeing composition containing a para-aminophenol or
                        para-phenylenediamine compound substituted with a
                        silane radical
```

Richard, Herve, Villepinte, FRANCE

NUMBER KIND DATE PATENT INFORMATION: US 2003150066 20030814 A1 APPLICATION INFO.: US 2002-259298 A1 20020930 (10)

> NUMBER DATE

PRIORITY INFORMATION: FR 2001-12523 DOCUMENT TYPE: Utility

FILE SEGMENT: APPLICATION

Thomas L. Irving, FINNEGAN, HENDERSON, FARABOW,, GARRETT & DUNNER, L.L.P., 1300 I Street, N.W., LEGAL REPRESENTATIVE:

20010928

Washington, DC, 20005-3315

NUMBER OF CLAIMS: 24 EXEMPLARY CLAIM: 1 LINE COUNT: 1016

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

IT 503534-45-0P

(oxidative hair dye compn. contg. silyl substituted aminophenol or

phenylenediamine derivs.)

RN 503534-45-0 USPATFULL

CN 1,4-Benzenediamine, 2-[2-(trimethylsilyl)ethyl]-, dihydrochloride (9CI)

(CA INDEX NAME)

$$\begin{array}{c} \text{NH}_2 \\ \text{CH}_2\text{--}\text{CH}_2\text{--}\text{SiMe}_3 \\ \\ \text{NH}_2 \end{array}$$

●2 HC1

L10 ANSWER 3 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 2

ACCESSION NUMBER: 2002:863862 CAPLUS DOCUMENT NUMBER: 139:53056

TITLE: Product subclass 39: benzylsilanes

AUTHOR (S): Bennetau, B.

CORPORATE SOURCE: Lab. de Chimie Organique et Organometallique, Talence,

F-33405, Fr.

SOURCE: Science of Synthesis (2002), 4, 825-836 CODEN: SSCYJ9

PUBLISHER: Georg Thieme Verlag DOCUMENT TYPE: Journal; General Review

LANGUAGE: English

548487-46-3

RL: RCT (Reactant); RACT (Reactant or reagent)

(benzylsilanes in org. synthesis: benzylation of electrophiles and

cycloaddn. with benzylsilanes)

RN 548487-46-3 CAPLUS

Cyclopentanone, 2-[3-[2-[(1R)-1-(dimethylamino)ethyl]phenyl]-3-

(trimethylsilyl)propyl]-3-ethenyl-2-methyl-, (2S,3S)-rel- (9CI) (CA INDEX

NAME)

Relative stereochemistry.

REFERENCE COUNT: 73 THERE ARE 73 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT ACCESSION NUMBER: 1998:119598 CAPLUS

DOCUMENT NUMBER: 128:225672

TITLE: Design, Synthesis, Derivatization, and

Structure-Activity Relationships of Simplified, Tricyclic, 1,2,4-Trioxane Alcohol Analogs of the

Antimalarial Artemisinin

Cumming, Jared N.; Wang, Dasong; Park, Sheldon B.; AUTHOR (S):

Shapiro, Theresa A.; Posner, Gary H.

CORPORATE SOURCE: Department of Chemistry School of Arts and Sciences,

Johns Hopkins University, Baltimore, MD, 21218, USA Journal of Medicinal Chemistry (1998), 41(6), 952-964

CODEN: JMCMAR; ISSN: 0022-2623

PUBLISHER: American Chemical Society

DOCUMENT TYPE: Journal LANGUAGE: English

204507-21-1P

RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT (Reactant or reagent)

(design, synthesis, derivatization, and structure-activity

relationships of simplified, tricyclic, 1,2,4-trioxane alc. analogs of

the antimalarial artemisinin)

RN 204507-21-1 CAPLUS

SOURCE:

2-Butanone, 3-[[3-[2-[[(1,1-dimethylethyl)dimethylsilyl]oxy]ethyl]-2-CN (methoxymethylene)cyclohexyl]methyl]-4-(trimethylsilyl)-, (1.alpha., 2E, 3.alpha.) - [partial] - (9CI) (CA INDEX NAME)

Relative stereochemistry. Double bond geometry as shown.

L10 ANSWER 5 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 4

ACCESSION NUMBER: 1997:634061 CAPLUS

DOCUMENT NUMBER: 127:293288

TITLE: Diastereo- and enantioselective synthesis of protected

vicinal silylamines via 1,2-addition to

.alpha.-silyl-hydrazones

AUTHOR (S):

Enders, Dieter; Leriverend, Catherine Institut Organische Chemie, Rheinisch-Westfalische CORPORATE SOURCE:

Technische Hochschule, Aachen, D-52074, Germany SOURCE: Tetrahedron: Asymmetry (1997), 8(16), 2787-2792

CODEN: TASYE3; ISSN: 0957-4166

PUBLISHER: Elsevier DOCUMENT TYPE: Journal

LANGUAGE: English OTHER SOURCE(S): CASREACT 127:293288

196931-90-5

RL: RCT (Reactant); RACT (Reactant or reagent)

(diastereo- and enantioselective synthesis of protected vicinal

silylamines via addn. to silylaldehyde-SAMP-hydrazones)

196931-90-5 CAPLUS RN

CN 1-Pyrrolidinamine, N-[2-[(1,1-dimethylethyl)dimethylsilyl]-3-

phenylpropylidene] -2 - (methoxymethyl) -, [S-[R*,R*-(E)]] - (9CI) NAME)

Absolute stereochemistry. Double bond geometry as shown.

L10 ANSWER 6 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 5

ACCESSION NUMBER: 1997:392506 CAPLUS

DOCUMENT NUMBER: 127:121775

TITLE: A chiral (alkoxy)methyl-substituted silicon group as an auxiliary for the stereoselective cuprate addition

to .alpha.,.beta.-unsaturated ketones: synthesis of

(-)-(R)-phenyl 2-phenylpropyl ketone

AUTHOR (S): Bratovanov, Svetoslav; Bienz, Stefan

CORPORATE SOURCE: Organisch-chemisches Institut, Universitat Zurich,

Zurich, CH-8057, Switz.

Tetrahedron: Asymmetry (1997), 8(10), 1587-1603 SOURCE:

CODEN: TASYE3; ISSN: 0957-4166

PUBLISHER: Elsevier DOCUMENT TYPE: Journal LANGUAGE: English

OTHER SOURCE(S): CASREACT 127:121775

192752-09-3P

RL: SPN (Synthetic preparation); PREP (Preparation)

(prepn. of)

RN

192752-09-3 CAPLUS
1-Butanone, 2-[(1,1-dimethylethyl)methyl[(phenylmethoxy)methyl]silyl]-1,3-CN

diphenyl-, [2R*(R*),3R*]- (9CI) (CA INDEX NAME)

Relative stereochemistry.

L10 ANSWER 7 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 6

ACCESSION NUMBER: 1995:819663 CAPLUS

DOCUMENT NUMBER: 124:56024

TITLE: Electrophilic additions to styrylsilanes: the effect

of changing the ligands on silicon AUTHOR (S):

Brook, Michael A.; Henry, Courtney; Jefferson, Elizabeth; Juschke, Ralf; Sebastian, Thomas; Tomaszewski, Mirek; Wenzel, Stefan

CORPORATE SOURCE:

Dep. chem., McMaster Univ., Hamilton, ON, L8S 4M1, Can.

SOURCE: Bulletin de la Societe Chimique de France (1995),

132(5-6), 559-68 CODEN: BSCFAS; ISSN: 0037-8968

PUBLISHER: Elsevier DOCUMENT TYPE: Journal

LANGUAGE: English OTHER SOURCE(S):

CASREACT 124:56024 171598-44-0P

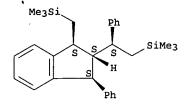
RL: SPN (Synthetic preparation); PREP (Preparation)

(crystal structure) 171598-44-0 CAPLUS

RN Silane, [[2,3-dihydro-3-phenyl-2-[1-phenyl-2-(trimethylsilyl)ethyl]-1H-CN inden-1-yl]methyl]trimethyl-, [1.alpha.,2.beta.(R*),3.alpha.]- (9CI) (CA

INDEX NAME)

Relative stereochemistry.



L10 ANSWER 8 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 7

ACCESSION NUMBER: 1994:30802 CAPLUS

DOCUMENT NUMBER: 120:30802

TITLE: Homolytic addition of cyclohexanol to

trialkylvinylsilanes Savos'kina, I. V.; Plugar, V. N.; Rashkes, Ya. V.; Galust'yan, G. G.; Terent'ev, A. B. AUTHOR (S):

CORPORATE SOURCE: Inst. Khim. Rastit., Tashkent, Uzbekistan

Uzbekskii Khimicheskii Zhurnal (1992), (5-6), 45-9 SOURCE:

CODEN: UZKZAC; ISSN: 0042-1707

DOCUMENT TYPE: Journal LANGUAGE: Russian

CASREACT 120:30802 OTHER SOURCE(S):

151885-68-6P

RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)

(prepn. and mass spectrum of)

RN 151885-68-6 CAPLUS

2-Cyclohexen-1-ol, 1-[2-(trimethylsilyl)ethyl]- (9CI) (CA INDEX NAME) CN

L10 ANSWER 9 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 8

ACCESSION NUMBER: 1991:559244 CAPLUS

DOCUMENT NUMBER: 115:159244

TITLE: Silicon effects. II. Structure and stability of

1-phenyl-2-(trimethylsilyl)ethyl cation in solution AUTHOR (S): Shimizu, Nobujiro; Watanabe, Shinichiro; Tsuno, Yuho

CORPORATE SOURCE: Fac. Sci., Kyushu Univ., Fukuoka, 812, Japan

SOURCE: Bulletin of the Chemical Society of Japan (1991),

64(7), 2249-54

CODEN: BCSJA8; ISSN: 0009-2673

DOCUMENT TYPE: Journal LANGUAGE: English

136272-29-2P RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT

(Reactant or reagent)

(prepn. and reaction of, with trifluoroacetic anhydride)

RN 136272-29-2 CAPLUS

Benzenemethanol, 3,5-dichloro-.alpha.-[(trimethylsilyl)methyl]- (9CI) (CA CN INDEX NAME)

L10 ANSWER 10 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 9

ACCESSION NUMBER: 1989:594181 CAPLUS

DOCUMENT NUMBER: 111:194181

TITLE: Carbonium ion rearrangements controlled by the

presence of a silyl group

Fleming, Ian; Patel, Shailesh K.; Urch, Christopher J. AUTHOR(S):

CORPORATE SOURCE: Univ. Chem. Lab., Cambridge, CB2 1EW, UK

Journal of the Chemical Society, Perkin Transactions SOURCE: 1: Organic and Bio-Organic Chemistry (1972-1999)

(1989), (1), 115-24

CODEN: JCPRB4; ISSN: 0300-922X

DOCUMENT TYPE:

Journal English

LANGUAGE: OTHER SOURCE(S):

CASREACT 111:194181

123315-07-1P

RL: SPN (Synthetic preparation); PREP (Preparation)

(prepn. and boron trifluoride acetic acid complex mediated

rearrangement of, alkene by)

123315-07-1 CAPLUS RN

Benzeneethanol, .alpha.-methyl-.alpha.-phenyl-.beta.-CN

[(trimethylsily1)methyl]-, (R*,R*)- (9CI) (CA INDEX NAME)

Relative stereochemistry.

L10 ANSWER 11 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 10

ACCESSION NUMBER:

1984:407242 CAPLUS 101:7242

DOCUMENT NUMBER:

Preparation of alkylvinylsilanes via

TITLE:

1-(phenylchalcogeno)-1-(trimethylsilyl)alkanes

AUTHOR (S):

Ogura, Fumio; Otsubo, Tetsuo; Ohira, Noriyuki;

CORPORATE SOURCE:

Yamaguchi, Hachiro Fac. Eng., Hiroshima Univ., Higashi-Hiroshima, 724,

Japan

SOURCE:

Synthesis (1983), (12), 1006-8 CODEN: SYNTBF; ISSN: 0039-7881

DOCUMENT TYPE: Journal

LANGUAGE:

English

OTHER SOURCE(S):

CASREACT 101:7242

90304-49-7P

RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT

(Reactant or reagent)

(prepn. and reaction of, with chloramine-T, vinylsilanes from)

90304-49-7 CAPLUS

Silane, trimethyl[3-phenyl-1-(phenylthio)propyl]- (9CI) (CA INDEX NAME) CN

SiMe₃

Phs-CH-CH2-CH2-Ph

L10 ANSWER 12 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 11

ACCESSION NUMBER:

1983:453827 CAPLUS

DOCUMENT NUMBER:

99:53827

TITLE:

Intramolecular Diels-Alder reactions of silicon-substituted dienes. Synthesis with

homoallylsilanes

AUTHOR (S):

Wilson, Stephen R.; Shedrinsky, Alexander; Haque, M.

Serajul

CORPORATE SOURCE:

Dep. Chem., New York Univ., New York, NY, 10003, USA

SOURCE:

Tetrahedron (1983), 39(6), 895-903 CODEN: TETRAB; ISSN: 0040-4020

DOCUMENT TYPE:

Journal English

LANGUAGE: 86487-04-9P

RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT

(Reactant or reagent)

(prepn. and desilylation of)

RN 86487-04-9 CAPLUS

Silane, [2-(3,4,4a,9,10,10a-hexahydro-6-methoxy-4a-methyl-1-CN phenanthrenyl)ethyl]trimethyl-, cis- (9CI) (CA INDEX NAME)

Relative stereochemistry.

L10 ANSWER 13 OF 13 CAPLUS COPYRIGHT 2003 ACS on STN DUPLICATE 12

ACCESSION NUMBER: DOCUMENT NUMBER:

1983:125571 CAPLUS

98:125571

TITLE:

Syntheses of polycyclic ring systems based on the new

generation of o-quinodimethanes

AUTHOR(S):

Ito, Yoshihiko; Nakatsuka, Masashi; Saegusa, Takeo

CORPORATE SOURCE: Fac. Eng., Kyoto Univ., Kyoto, 606, Japan Journal of the American Chemical Society (1982),

SOURCE:

104(26), 7609-22 CODEN: JACSAT; ISSN: 0002-7863

DOCUMENT TYPE:

Journal English

LANGUAGE: OTHER SOURCE(S):

CASREACT 98:125571

83781-88-8P

RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT

(Reactant or reagent)

(prepn. and cyclization of) 83781-88-8 CAPLUS

RN

Benzenemethanaminium, 2-[3-(2-ethenyl-5-oxocyclopentyl)-1-CN

(trimethylsilyl)propyl]-5-methoxy-N,N,N-trimethyl-, iodide (9CI)

INDEX NAME)

SiMe₃

$$CH-CH_2-CH_2$$

$$CH_2-N+Me_3$$

$$H_2C=CH$$

• I-